

Instructions for Use

CIM[®] C4 HLD 0.2 mL Monolithic 96-well Plate (2 μ m channels)

CIM Convective Interaction Media[®]
120.8136-2



SARTORIUS

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1. About These Instructions for Use

These instructions are part of the device. They apply to the device product number indicated on the cover page.

2. Safety

WARNING

Denotes a hazard that may result in death or severe injury if it is not avoided.

CAUTION

Denotes a hazard that may result in moderate or minor injury if it is not avoided.

NOTICE

Denotes a hazard that may result in property damage if it is not avoided.

2.1. Intended Use

CIM® monolithic plates are standard format plates prefilled with unique monolithic chromatographic media intended for diagnostic or screening purposes. They enable high-throughput process development through fast and efficient evaluation of binding, washing, elution conditions and other chromatographic parameters. The properties of the medium are directly comparable to CIM® chromatographic columns, making monolithic plates a robust tool in early process development stages.

CIM® monolithic 96-well plates are used for fast and highly efficient screening of samples or purification parameters for proteins, viral particles, and pDNA under hydrophobic conditions. The following information is being provided to ensure proper product care and optimal product performance.

2.2. Safety Note

Follow the guidelines in this Instructions for Use. Improper use may result in malfunction, personal injury, or damage of the product or material. Follow safety instructions, wear gloves, safety glasses, and a lab coat during operation.

3. Technical Data

Column chemistry	C4 HLD (hydrophobic; butyl – high ligand density)
Channel radius	1050 nm (950 nm – 1150 nm)
Support matrix	Poly(butyl methacrylate -co- ethylene dimethacrylate)

Monolith dimensions	Diameter: 7.35 mm; length: 4.8 mm; monolith volume: 0.2 mL
Plate format	127 x 85.5 x 44 mm, plate material: polypropylene (PP) and polyethylene (HDPE)
Well load volume (WV)	Up to 1600 µL, 96 wells
Operating parameters	Operating vacuum between -0.015 and -0.03 MPa -0.15 and -0.3 bar -2.18 and -4.35 psi; Maximum vacuum -0.06 MPa -0.6 bar -8.7 psi; Operating centrifugation force 500 g; Maximum centrifugation force 1000g; Operating positive pressure between 9 and 11 psi; Maximum positive pressure 15 psi.
Dynamic binding capacity	N.D.
Operating temperature	4 °C (39 °F) to 40 °C (104 °F)
Chemical stability	All commonly used aqueous buffers, such as 1 M NaOH, 0.1 M HCl, 3 M ammonium sulphate, 8 M urea and 6 M guanidine hydrochloride. Avoid oxidising agents and organic solvents, such as methanol, ethanol, acetonitrile, 2-propanol. Avoid prolonged use of concentrated acids (more than 0.5 M) such as hydrochloric, sulphuric or acetic acid.
Recommended pH	Working range 3–13, cleaning in place 1–14
Storage conditions	2 °C (36 °F) to 25 °C (77 °F); store in 10 mM NaOH.
Shelf life	7 years

4. Installation

Remove the product from its shipping box or crate and place on a flat surface. Carefully inspect the product for any damage that may have occurred during shipping. Immediately report any such damage to your vendor and the courier. The product is shipped in the designated storage solution at ambient temperature and should be stored upon receiving as stated under Technical Data.

NOTICE

Do not store the product below 0 °C (32 °F).

5. Getting Started

The plate does not require a fully automated robot system and can be operated using a vacuum manifold or centrifuge. Operating parameters can be found under Technical Data. Before use, remove the top and bottom cover seals and remove storage solution by vacuum or centrifugation.

Note: When using a vacuum manifold with a vacuum pump, the maximum separation between the bottom of the plate and the top of the collection plate should not exceed 5 mm to prevent cross contamination. Turn off the vacuum as soon as the sample/solution is removed.

Note: With a centrifuge, ensure the collection plate well volume is suitable for the intended loading volume. Centrifuge the plate until the sample/solution is removed. Adjust centrifugation time accordingly.

5.1. General Recommendations

The following are general guidelines to consider when working with chromatography. The guidelines may not apply to specific plate chemistry or sample properties.

- Treat loading material appropriately (e.g. pre-treat, filter, concentrate / dilute, etc.). For more details, please refer to the Guideline 'Pre-treatment of complex biological samples before column purification and regeneration procedures for columns with increased back pressure' (biaseparations.com/en/library/guidelines).
- Always use freshly prepared mobile phases, filtered through 0.2 µm filter, compatible with mobile phases.
- Air bubbles will not disturb the stationary phase and can be washed out of the plate. However, drying the monolith risks damaging the stationary phase.
- Surfactants can improve recoveries in virus purification. Non-ionic surfactants will not interact with ion exchange chromatography media. Non-UV-absorbing (at working wavelengths) surfactants will improve the baseline signal.
- Ensure all components of the system used are compatible with the working solutions (e.g. sodium hydroxide, organic solvents, high salt concentrations, etc).

NOTICE

Always ensure mobile phases are compatible before mixing them or applying consecutively on the plate. Examples of in-compatible buffers are: magnesium ion-containing buffers and sodium hydroxide (forms precipitate), acetonitrile and sodium hydroxide (forms ammonia and acetate), ammonium acetate and sodium hydroxide (potential formation of explosive atmosphere), ethanol and sodium hydroxide (forms ethoxides). Wash the plate with water or another compatible solution when using two incompatible solutions consecutively.

6. Operating the Plate

6.1. Equilibration

For robust and consistent operation of the plate, equilibration should be performed before starting with sample analysis when the plate was stored, regenerated or cleaned in place. Flush any storage or cleaning solution out of each well by washing with 2 WV of deionised water. Equilibration buffer should have the same or similar composition to the loaded sample.

1. If needed wash each well with 2 WV of water to prevent mixing of incompatible buffers.
2. Wash each well with at least 3 WV of elution mobile phase.
3. Wash each well with at least 2 WV of binding mobile phase. The composition of this mobile phase should be similar to the sample composition.

6.2. Strip | Regeneration

A strip is typically implemented in the screening run to remove tightly-bound sample components. It is common to use the same approach as the elution: low ionic strength mobile phase or water.

We recommend to clean the plate after screening run. See the section Cleaning in Place.

7. Cleaning | Maintenance

Cleaning and maintenance of the device may improve its lifetime and increase reproducibility. Sample properties should be taken into account for plate cleaning.

7.1. Cleaning in Place (CIP)

In some cases, a simple regeneration of the plate is not sufficient. Sample molecules may not completely elute from the plate or may even precipitate on the plate. This build-up of contaminants on the monolithic plate may cause loss of resolution and binding capacity or a complete blockage of the plate. A specific CIP procedure should be designed for the type of contaminants present in the sample. In most cases the following procedure can be used:

1. Wash each well with at least 2 WV of deionised water.
 2. Wash each well with at least 2 WV of 1 M NaOH.
 3. Wash each well with at least 2 WV of deionised water.
 4. Wash each well with at least 2 WV of a concentrated buffer (e.g. 0.1 M–0.5 M buffer) to restore the appropriate pH.
- Note:** Binding buffer may be used for this step. Wash until the pH value at the outlet of the plate corresponds to the buffer's pH.

8. Storage

Wash the plate with at least 2 WV per well of deionized water and proceed with at least 2 WV per well of storage solution. Add storage solution to each well. Seal the plate and store at the temperature specified in the table Technical Data. If there is a possibility of biological contamination from the sample it is recommended to store the plate between 2 °C (36 °F) and 8 °C (46 °F).

Note: Clean and equilibrate the plate before long-term storage.

Note: NaOH-ethanol mixtures at any concentration form ethoxide anions that are highly destructive to biomolecules. Caution is recommended. Neutralise the plate environment before introducing ethanol.

9. Troubleshooting

Problems arising during the analysis are usually related to the device, sample, mobile phase, or the instrumentation. It is advisable to use an elimination approach to exclude possible causes. Please refer to our troubleshooting guide (biaseparations.com/en/library/guidelines).

10. Decommissioning | Transportation

If there is reason to return the product, complete a Return Form (biaseparations.com/en/terms-conditions) and contact help.bia@sartorius.com.

Contaminated samples used during the process that could cause biological or chemical hazards are potentially hazardous substances. If the product has come into contact with hazardous substances, steps must be taken to ensure proper decontamination and declaration.

Procedure

Decontaminate the product. The operator of the product is responsible for adhering to local government regulations on the proper decontamination and declaration for transport and disposal.

11. Ordering Information

Transferring the workflow to a different scale or format (analytical, screening) is simple with CIM®. Contact your local support to find the appropriate products.

Purification Scale Products

Catalog number	Product name
311.8136-2	CIMmultus® C4 HLD 1 mL Monolithic Column (HLD Butyl) (2 µm channels)
414.8136-2	CIMmultus® C4 HLD 4 mL Monolithic Column (HLD Butyl) (2 µm channels)
411.8136-2	CIMmultus® C4 HLD 8 mL Monolithic Column (HLD Butyl) (2 µm channels)
614.8136-2	CIMmultus® C4 HLD 40 mL Monolithic Column (HLD Butyl) (2 µm channels)
611.8136-2	CIMmultus® C4 HLD 80 mL Monolithic Column (HLD Butyl) (2 µm channels)
814.8136-2	CIMmultus® C4 HLD 400 mL Monolithic Column (HLD Butyl) (2 µm channels)
811.8136-2	CIMmultus® C4 HLD 800 mL Monolithic Column (HLD Butyl) (2 µm channels)
1014.8136-2	CIMmultus® C4 HLD 4000 mL Monolithic Column (HLD Butyl) (2 µm channels)
1011.8136-2	CIMmultus® C4 HLD 8000 mL Monolithic Column (HLD Butyl) (2 µm channels)

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